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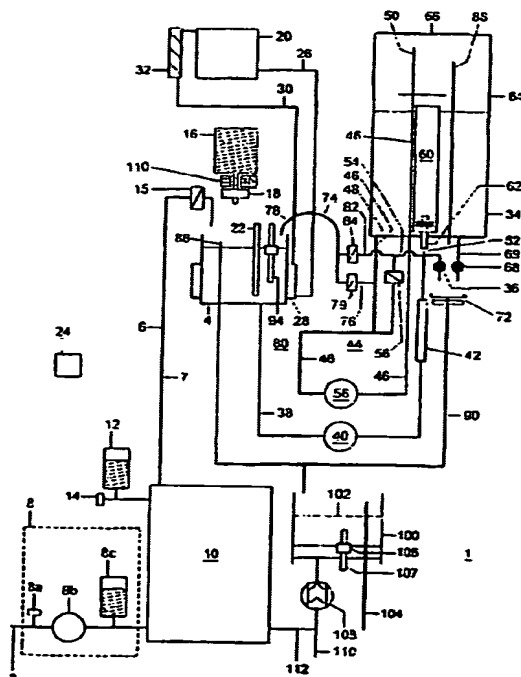
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(54) Title: WATER SUPPLY APPARATUS AND CLEANING SYSTEM FOR CLEANING THE WATER SUPPLY APPARATUS

(57) Abstract: A cleaning system designed for cleaning a wa-  
ter supply apparatus which is provided with: a tap water inlet  
(2); a mineral dosing unit (18) with the aid of which, on the  
basis of tap water, mineral water can be generated; water pro-  
cessing means and a control unit (24) designed for controlling at  
least a part of the water processing means according to a prede-  
termined water processing program for the purpose of present-  
ing mineral water, the cleaning system being provided with at  
least one cleaning agent vessel (H) from which, in use, cleaning  
agent can be supplied, directly or indirectly, to the water sup-  
ply apparatus, wherein the cleaning system is provided with  
a cleaning system control unit designed for controlling at least  
a part of the water processing means according to a predeter-  
mined cleaning program for the purpose of a cleaning at least a  
part of the water processing means.

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